Business Briefing about Our Products for Semiconductor Production Equipment

(Our high-performance stainless steel business)



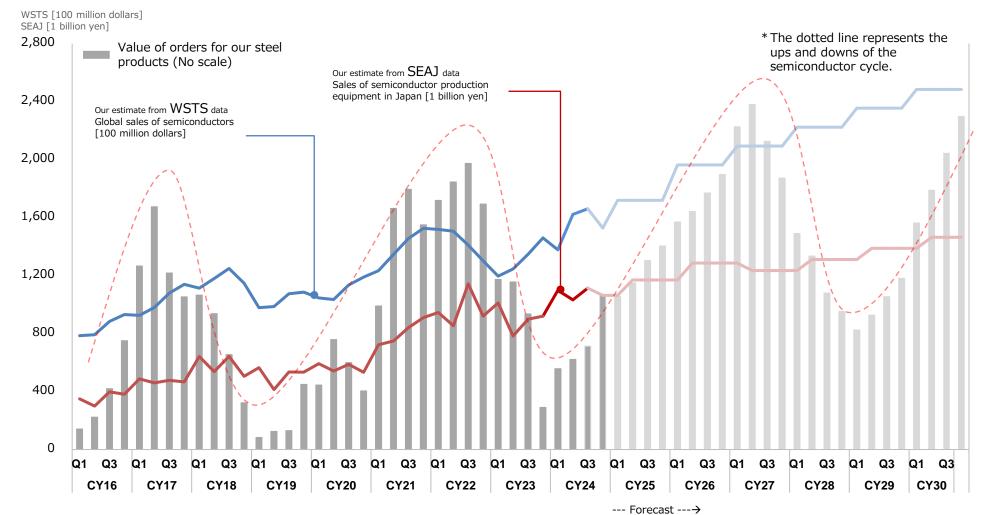
Daido Steel Co., Ltd. (Securities code: 5471)

January 15, 2025



1. Semiconductor Demand and Orders for Our Related Products

The demand for semiconductors and semiconductor production equipment is expected to increase from 2026 to 2030. Orders for our semiconductor-related products are also expected to increase in line with market expansion.



^{*} WSTS: World Semiconductor Trade Statistics

^{*} SEAJ: Semiconductor Equipment Association of Japan



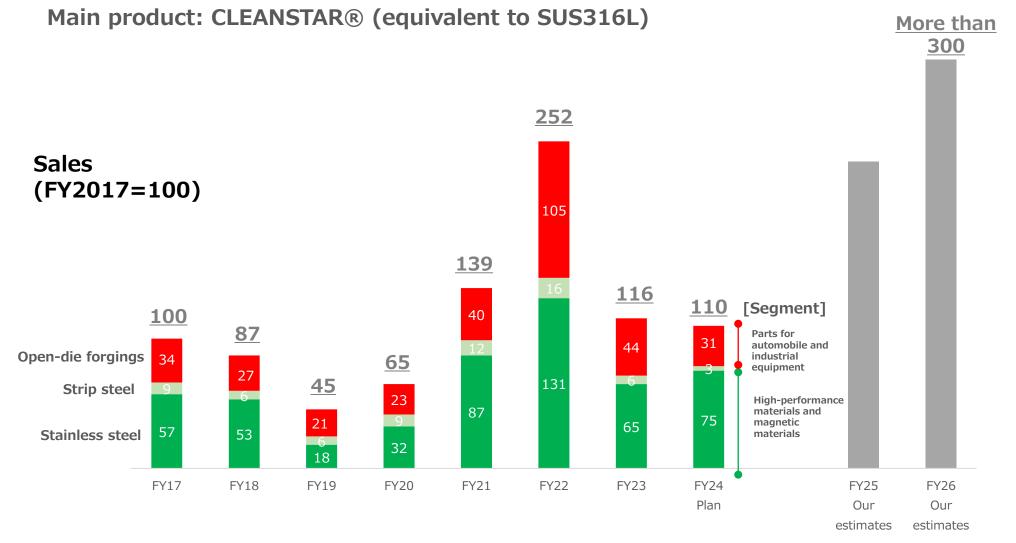
2. Sales by Segments and Semiconductor-related Products



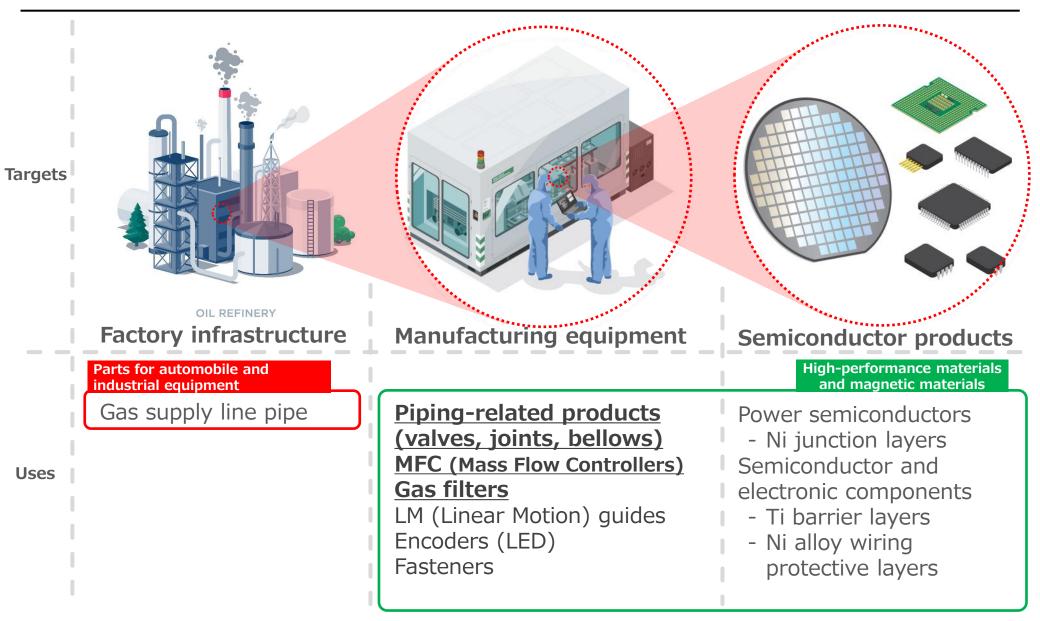
(FY2023 results: Japanese GAAP)

3. Sales Trends for Semiconductor Production Equipment (non-consolidated basis)

▼ The sale of semiconductor production equipment products is expected to more than triple in FY2026 over FY2017 sales.



4. Specialty Steel Applications in the Semiconductor Industry



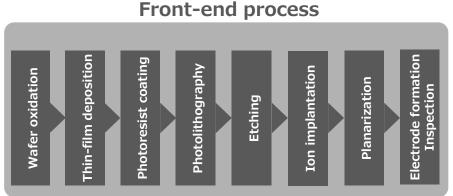
5-1. Overview of the Semiconductor Production Process

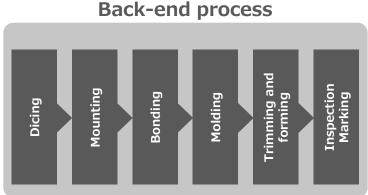
Three major processes contribute to the manufacture of semiconductors:

Silicon manufacturer

Semiconductor manufacturer

Ingot pulling
Ingot slicing
Wafer polishing



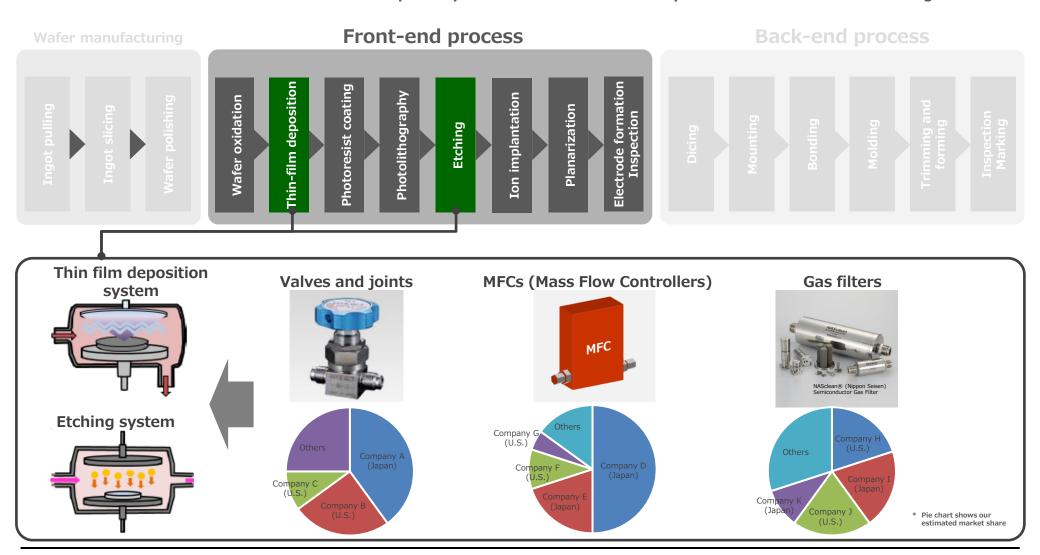


Required steel characteristics

		Required Steel Characteristics			
Production processes	Outline of the separate processes	Corrosion resistance Resistance to corrosion, especially from corrosive gases	Surface cleanliness Cleanliness of the steel's surface Very low level of impurities	Low levels of thermal expansion Limited expansion and contraction due to changes in temperature	
Wafer manufacturing	The process of producing silicon wafers, wherein high-purity silicon ingots are created, sliced and then polished		0	\bigcirc	
Front-end process	This is where a silicon wafer is prepared, making it ready to serve as a substrate for the formation of electronic components that will perform functions such as power control, signal amplification, and data storage.	0	0		
Back-end process	This is where a wafer with electronic components formed on it is cut (diced) into individual chips, which are then packaged as finished products.	0 0 0 0		\bigcirc	

5-2. Our Business Opportunities in the Front-end Process

- Corrosive gases are used by equipment that performs thin film deposition and etching in the front-end process
 - Corrosion-resistant stainless steel and superalloy steel are used because they can withstand these corrosive gases -



5-3. Our Business Opportunities within the Overall Process

- Various component parts of the semiconductor factory infrastructure and the manufacturing equipment
 - Stainless steel is widely used to make gas supply lines and semiconductor production equipment components -

Front-end process **Back-end process** Wafer manufacturing Electrode formation **Thin-film deposition** implantation **Nafer** polishing **Wafer oxidation Photolithography** Ingot pulling Planarization Ingot slicing Inspection Marking Inspection Molding Bonding

Daido Steel's products are used extensively throughout the entire semiconductor manufacturing process.

Gas supply line pipe



Our VIM-VAR steel pipes have a high market share in the field of corrosive gas supply lines, etc.

LM guides



Our long-life stainless steel (DSR7) has a high market share, for use as a material to make LM guides for various types of equipment.

Fasteners



Daido Steel's 316L wire rods and steel bars are widely used as a material for making fasteners (for example, nuts and bolts).

Bellows



Bellows manufactured using stainless steel and superalloy strip steel are also included as parts for semiconductor production equipment.

6. Our Stainless Steel Products for Semiconductor Production Equipment 1

► Introducing CLEANSTAR®

*SEMI Standards: These international standards are used in the semiconductor industry. They were established by Semiconductor Equipment and Materials International (SEMI).

Product overview

- ·CLEANSTAR®, a super-clean stainless steel developed by Daido, meets JISG4303 and SEMI F20(*) international standards.
- · High-level cleanliness & optimized chemical composition provide superior corrosion resistance, compared to Type 316L.
- Three steel grades, to suit the particular manufacturing process in terms of application and required characteristics.

	Main process	Typical major components (mass%)					
Steel grades	Primary / Secondary	С	Mn	S	Ni	Cr	Мо
CLEANSTAR-A	VIM / VAR	0.006	Extremely low Mn	Extremely low S	14.7	16.7	2.2
CLEANSTAR-B	AF / VAR	0.007	Low Mn	Extremely low S	14.7	16.7	2.2
CLEANSTAR-C	AF / -	0.015	1.8	Low S	12.1	16.7	2.0
Type 316L		0.030 or less	2.00 or less	0.030 or less	12.00 to 15.00	16.00 to 18.00	2.00 to 3.00

Process selection according to required characteristics (Please see page 11)

Reduced elements that adversely affect corrosion resistance

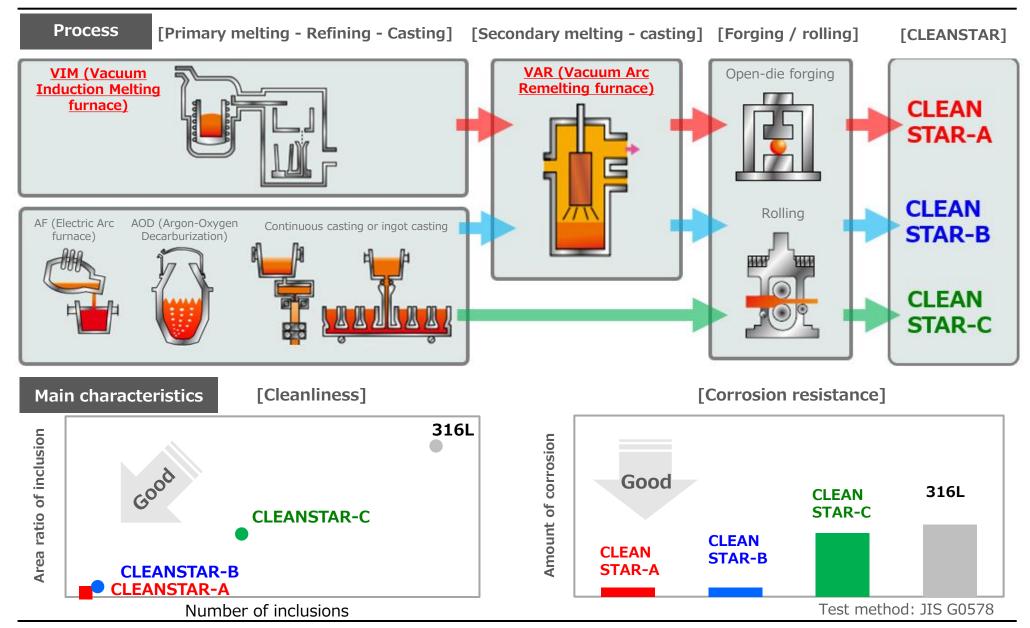
Manufacturing technology

- Inclusions that may cause the admixture of foreign matter into a product have been minimized through the use of technology we cultivated as a manufacturer of aircraft materials and ultrafine metal wire.
- <u>Elements that can undermine corrosion resistance have been minimized</u> through our unique chemical composition design and manufacturing processes.



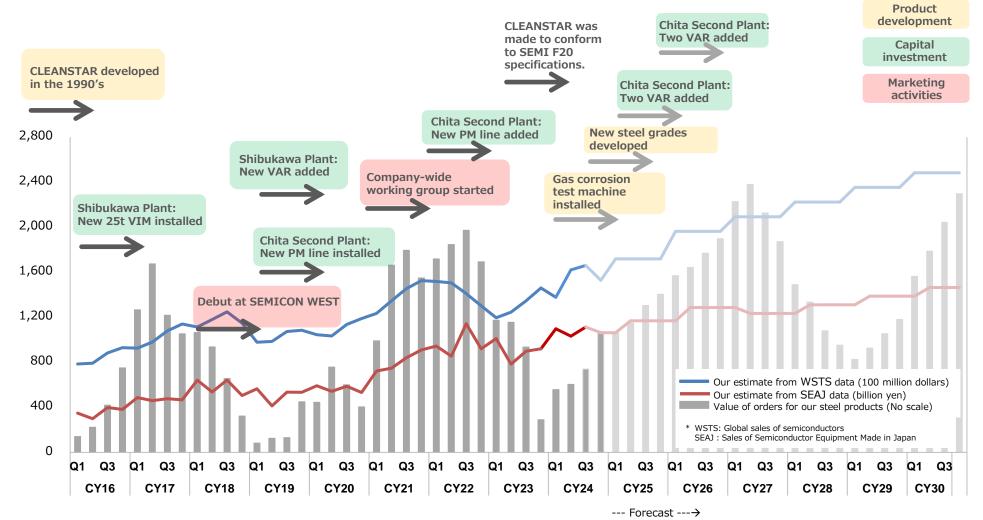
CLEANSTAR® is widely used as a material for semiconductor production equipment parts that are used where corrosive gases flow.

6. Our Stainless Steel Products for Semiconductor Production Equipment ②



7. Our Measures to Promote Semiconductor Business Growth

Promote product development, capital investment, and marketing activities in anticipation of growing future demand

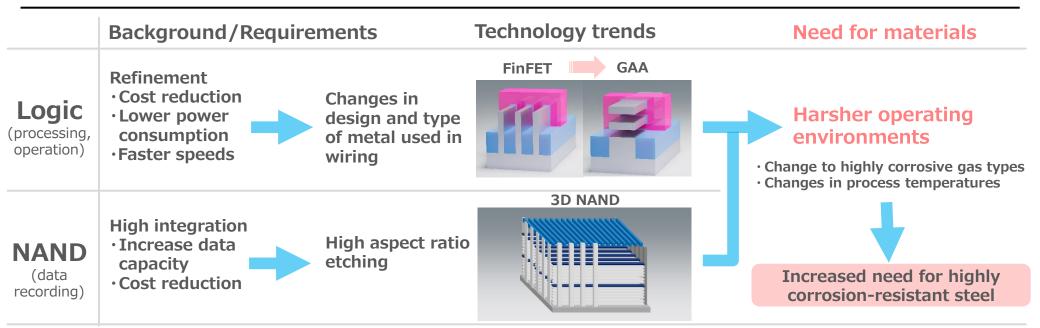


* SEAJ : Semiconductor Equipment Association of Japan

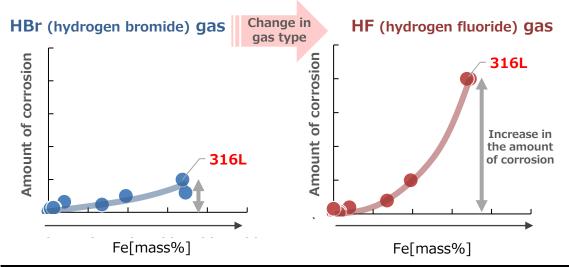
^{*} WSTS: World Semiconductor Trade Statistics

8-1. Technology Trends and Need for Corrosion-Resistant Materials





♦ Results of corrosion-resistance evaluation by gas type and material (our own test)

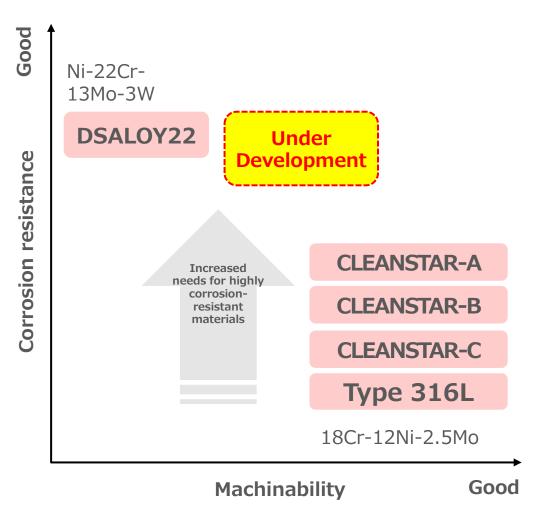


With the frequent use of highly corrosive gases, demand for higher corrosion resistance material would increase to replace Type 316L.

- ⇒ Installed the gas corrosion testing machine
- ⇒ Consider developing a new material with high corrosion resistance & low cost

^{*} FinFET: Fin Field-Effect Transistor, GAA: Gate-All-Around Transistor 3D NAND: 3D NAND flash memory

→ Development of new steel grades for corrosive gas environments



Where corrosion resistance is needed

Title C Coll Colon i Colonario io il Coaca			
Product group	Present situation		
DSALOY22 (equivalent to Hastelloy® C22®)	 For applications that require even higher corrosion resistance than CLEANSTAR provides, with highly corrosive gases and high temp environments. Currently developing a new material to meet the demand for highly corrosion-resistant materials with improved machinability 		
CLEANSTAR Type 316L	 CLEANSTAR-A, -B, and -C, according to the type of gas involved and the environment in which it is used. 		

^{*} Hastelloy and C22 are registered trademarks of Haynes International Inc.

Where improved machinability is needed

Process	Explanation				
РМ	 To peel steel bar's surface to adjust its dimensions and smooth its surface. 				
Drawing	To stretch steel coil at room temperature to adjust diameter dimensions				
Machining	To grind off material outside the boundaries of the shape to create the shapes of parts				

<Reference> Typical manufacturing processes for making parts



8-2. Our Development & Evaluation Technology



> High-temperature gas corrosion testing equipment is currently being evaluated.

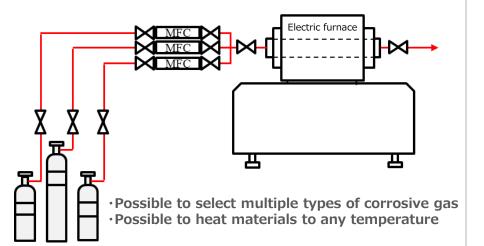
This equipment is used to replicate the operating environment in which steel materials are used during etching and thin film deposition. It makes it possible to evaluate corrosion resistance in situations that closely resemble those of actual manufacturing practice.

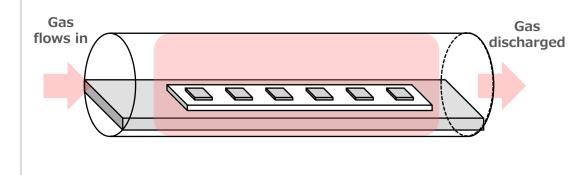
Equipment overview

Inside electric furnace







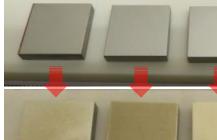


<Reference> Differences in corrosion resistance by material (test specimen appearance) Corrosive gas: HF

Material A

Before

Material B



After testina

testina

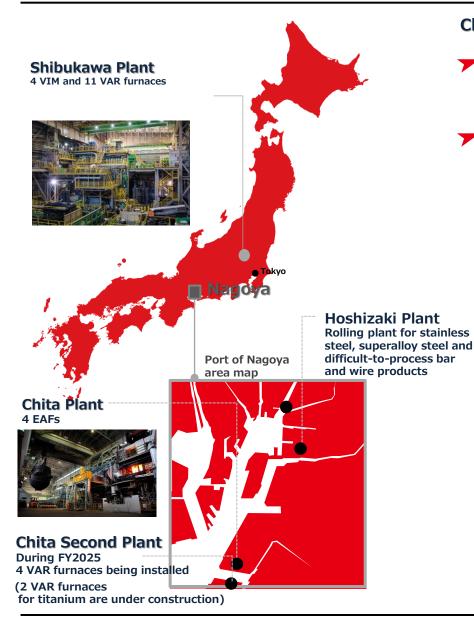


Material C

Material D

Material E

9. Our Capital Investments for Expanding Manufacturing Capacity



Chita Second Plant ("Smart" factory)

Reallocation of production resources

Stainless steel production equipment for SPE application being installed at the Chita Second Plant Secondary melting and subsequent processes integrated in the Nagoya area

<u>Capacity expansion for high-performance materials</u> stainless steel for semiconductor production equipment and superalloy steel

A total of four VARs will be installed at the Chita Second Plant, adjacent to the Chita Plant. The 1st VAR furnace started in December 2024 and the 2nd will start in March 2025. The remaining two furnaces are scheduled to start operating by the end of FY2025.

Chita Second Plant and Chita Plant



High-temperature gas corrosion test laboratory (under test operation)



VAR (started operating in Dec. 2024.)



Heat treatment and machining equipment (fully operating)



Main activities for overseas markets

1. Our exhibition at SEMICON WEST (from 2018 to 2024)

Exhibition booth at SEMICON WEST in North America





SEMICON WEST exhibition:

2018: 1st Exhibition 2019: 2nd Exhibition

2020: Virtual exhibition due to COVID-19

2021: HYBRID exhibition (virtual) 2022: HYBRID exhibition (on-site)

2023: 6th Exhibition 2024: 7th Exhibition

2. PR activities by Daido Steel's overseas group networks

North America: Activities to meet the needs of the North American market, such as exhibiting

products at SEMICON and bringing CLEANSTAR products into compliance with

SEMI standards

Aggressive development of new customers through Daido Steel (America) Inc.

China: PR promotion to the world's largest semiconductor market, by utilizing sales

networks such as Daido Steel (Shanghai) Co., Ltd.

Europe: Daido Steel Group Europe (Germany) conducted a survey of the European

semiconductor market

11. Daido Steel's Strength for Semiconductor Production Equipment

Sufficient upward elasticity of produciton capacity

Top manufacturing capacity in Japan Comparable to U.S. competitors Timely capital investments executed in anticipation of increased future demand

Manufacturing capacity

Ability to develop new materials and processes

Best quality, wide product range

Our expertise in manufacturing aircraft materials and ultra-fine wire materials puts us ahead. In addition to CLEANSTAR-A, -B, and -C, currently developing new grade that brings together the desirable characteristics of corrosion resistance and machinability.

Sources of our domestic and international marketing power

Our products secure overwhelming market share through co-creation relationships with major manufacturers of SPE parts.

In addition, we keep on developing new customers through our overseas group marketing activities.

Solid customer <u>base</u>

Flexible and short time delivery

Drastic reallocation of production resources

Currently promoting reallocation of production resources by utilizing Chita Second Plant.

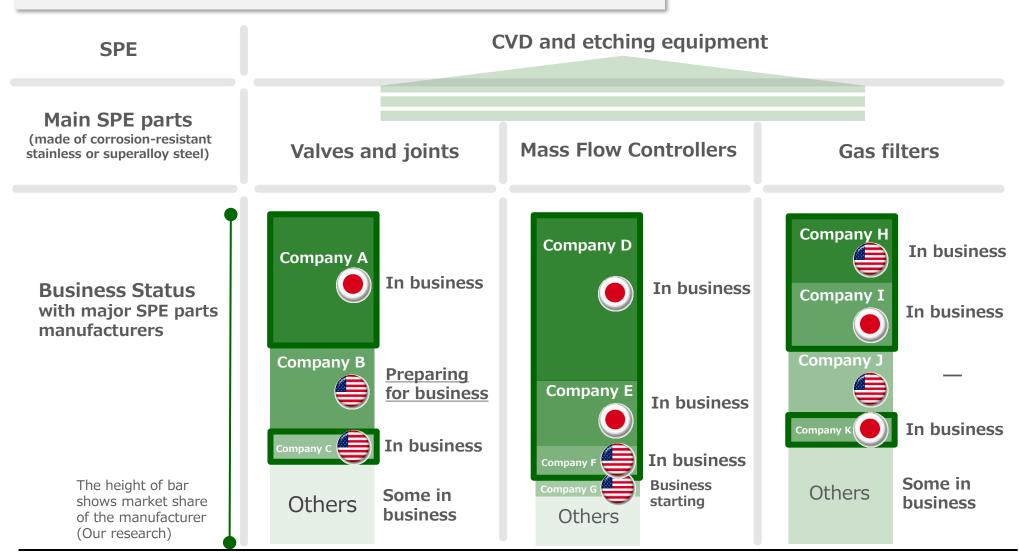
We manage inventories according to increasing demand.

^{*} SPE: semiconductor production equipment

12. Our Business Status with Major SPE Parts Manufacturers

Global market shares of our high-performance stainless steel bars and wire rods

Current: 40% FY2026: 50%



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